



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No.10/624,628
Filing Date July 21, 2003
Inventor.....Luan C. Tran
AssigneeMicron Technology, Inc.
Group Art Unit2812
ExaminerKennedy, Jennifer M.
Attorney's Docket No.MI22-2356
Title: Methods of Forming Semiconductor Constructions

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT
References -See Attached Form PTO-1449

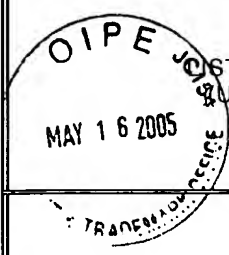
The attached form PTO-1449 is submitted in compliance with 37 CFR §1.56.
Copies of the cited art are included with the exception of U.S. patents and published U.S. applications (1276 OG 55). No admission is made regarding whether all the submitted references are prior art.

Respectfully submitted,

Dated: May 16, 2005

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Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. MI22-2356		SERIAL NO. 10/624,628	
 LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Luan C. Tran			
				FILING DATE July 21, 2003		GROUP 2812	
U.S. PATENT DOCUMENTS							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA	5,970,352	10/99	Shiozawa et al.			
	AB	6,001,707	12/99	Lin et al.			
	AC	6,420,749	07/02	Divakaruni et al.			
	AD	6,187,624	02/01	Huang			
	AE	5,946,568	08/99	Hsiao et al.			
	AF	6,242,329	06/01	Huster et al.			
	AG	4,985,740	01/91	Shenai et al.			
	AH	US2002/0006693	01/02	Matsuda			
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation
							Yes No
	AP						
	AQ						
	AR						
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)							
	AS		Wolf et al., "Silicon Processing for the VLSI Era, Vol. 1: Process Technology," Second Edition, Lattice Press 2000, pp.12-13, 25-27.				
	AT		S.M. Sze, VLSI Technology, Second Edition, McGraw-Hill, 1988, pages 472-483				
EXAMINER				DATE CONSIDERED			
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							